



OPTICAL DEPOSITION LABORATORY

Specification for “UV IR Block”

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Page 1 of 2

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OPTICAL DEPOSITION LABORATORY

Technical Data:

UV Block and Heat Reflex01:

Tavg. \leq 3% for $300\text{nm} < \lambda < 380\text{nm}$
Tavg. \geq 85% **$450\text{nm} < \lambda < 670\text{nm}$**
Ravg. \geq 95% **$750\text{nm} < \lambda < 950\text{nm}$**
 $i = 0^\circ$

UV Block and Heat Reflex02:

Tavg. \leq 3% for $300\text{nm} < \lambda < 380\text{nm}$
Tavg. \geq 85% **$450\text{nm} < \lambda < 670\text{nm}$**
Ravg. \geq 95% **$750\text{nm} < \lambda < 1140\text{nm}$**
 $i = 0^\circ$

UV IR Block

